

Two Days Hands-on Workshop on Design and Fabrication of Semiconductor Devices

Under
CSIR- Integrated Skill Initiative (CSIR-ISI) Programme
On 10th & 11th March, 2026

Highlights of Workshop:

- ❖ Knowledge and Practical Exposure on Semiconductor Devices:
 - Global and National Overview of Semiconductor Initiatives
 - Device fabrication: oxidation, diffusion, and lithography
 - Electrical characteristics and performance parameters of devices
 - Hands-on exposure/demonstrations
 - Applications of semiconductor devices in ICs, sensors, and power electronics
 - Interaction with experts and discussion on current industry trends
- ❖ Convert your idea into industry by getting grant of Rs. 70 Lakh (Rs 20 Lakh for Product Development & Rs 50 Lakh to start own industry of developed product) under PRISM Scheme of DSIR. The innovator can contact/apply to DSIR-TOCIC, CSIR-CSIO, Chandigarh for further assistance/guidance regarding PRISM Scheme.

Venue:

Center for Nano & Optics Fabrication (CINOF)
CSIR-CSIO, Chandigarh

Registration Fee

Amount : INR 1000/- Including GST

Payments Details

Bank Name: SBI, Sector-30, Chandigarh
Account Name: Director, CSIR-CSIO, Chandigarh
Account No: 30267029400
IFSC Code: SBIN000 1443

QR Code for
payment



Eligibility:

Students having/pursuing B.Tech/ M.Sc/M.Tech/Phd.,
Industry representative, Faculties, Scientists

Note: Limited seats only for first 20 candidates for skill training course with certificate. Please email us your payment receipt after registration.

Last Date of Registration : 5th March, 2026

Registration details

Register yourself with the link or QR code given bellow:

<https://forms.gle/2zns4R5yFgTo6N1D8>

For more information, please contact @ nsjassal.csio@csir.res.in



For updates related to PRISM scheme and skill Trainings, visit
websites : <https://www.csio.res.in>,